Impedance studies of polycrystalline tin oxide

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In Figs. 4 and 5 the y-axis parameter printed is not correct although the curves therein represent the experimental data as mentioned in the paper. The corrected parameter for the y-axis for Figs. 4 and 5 is $1/\omega C_s$ in Ohms.

Fig. 4 Impedance plot at various temperatures of polycrystalline SnO₂ without He implantation

Fig. 5 Impedance plot at various temperatures of polycrystalline SnO₂ with He implantation

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